10/645,253 SESSION ENTRY 0.21 0.21 FULL ESTIMATED COST FILE 'USPATFULL' ENTERED AT 09:44:10 ON 07 FEB 2006 CA INDEXING COPYRIGHT (C) 2006 AMERICAN CHEMICAL SOCIETY (ACS) FILE COVERS 1971 TO PATENT PUBLICATION DATE: 2 Feb 2006 (20060202/PD) FILE LAST UPDATED: 2 Feb 2006 (20060202/ED) HIGHEST GRANTED PATENT NUMBER: US6993790 HIGHEST APPLICATION PUBLICATION NUMBER: US2006026727 CA INDEXING IS CURRENT THROUGH 2 Feb 2006 (20060202/UPCA) ISSUE CLASS FIELDS (/INCL) CURRENT THROUGH: 2 Feb 2006 (20060202/PD) REVISED CLASS FIELDS (/NCL) LAST RELOADED: Dec 2005 USPTO MANUAL OF CLASSIFICATIONS THESAURUS ISSUE DATE: Dec 2005 3189 => s avobenzone? or parsal 1789 439 AVOBENZONE? 2 PARSAL 5697 1789 0 PARSAL 1789 (PARSAL(W)1789) 439 AVOBENZONE? OR PARSAL 1789 Ll => s avobenzone? or parsol 1789 439 AVOBENZONE? 1636 PARSOL 5697 1789 954 PARSOL 1789 (PARSOL(W) 1789) L21274 AVOBENZONE? OR PARSOL 1789 => s 12/clm87 AVOBENZONE?/CLM 28 PARSOL/CLM 223 1789/CLM

103 (AVOBENZONE?/CLM OR PARSOL 1789/CLM)

=> s zinc oxide?

L3

250447 ZINC

685252 OXIDE?

64772 ZINC OXIDE? L4

(ZINC(W)OXIDE?)

22 PARSOL 1789/CLM

=> s 14/clm

50013 ZINC/CLM

197817 OXIDE?/CLM

10758 (ZINC OXIDE?/CLM) L5

((ZINC(W)OXIDE?)/CLM)

((PARSOL(W)1789)/CLM)

=> s phenylbenzimidazole sulfonic acid?

1933 PHENYLBENZIMIDAZOLE

111185 SULFONIC

862757 ACID?

L6 338 PHENYLBENZIMIDAZOLE SULFONIC ACID?

(PHENYLBENZIMIDAZOLE (W) SULFONIC (W) ACID?)

=> s 16/clm

250 PHENYLBENZIMIDAZOLE/CLM

17988 SULFONIC/CLM

```
10/645,253
        381593 ACID?/CLM
            69 (PHENYLBENZIMIDAZOLE SULFONIC ACID?/CLM)
L7
                 ((PHENYLBENZIMIDAZOLE(W)SULFONIC(W)ACID?)/CLM)
=> s 13 and 16 and 17
            26 L3 AND L6 AND L7
L8
=> s sunscreen? or uv sunblock?
          8768 SUNSCREEN?
        176726 UV
           733 SUNBLOCK?
            12 UV SUNBLOCK?
                 (UV (W) SUNBLOCK?)
          8768 SUNSCREEN? OR UV SUNBLOCK?
L9
=> s 19/clm
          2440 SUNSCREEN?/CLM
         15950 UV/CLM
           103 SUNBLOCK?/CLM
             0 UV SUNBLOCK?/CLM
                ((UV(W)SUNBLOCK?)/CLM)
          2440 (SUNSCREEN?/CLM OR UV SUNBLOCK?/CLM)
L10
=> s 110 and 18
        25 L10 AND L8
L11
=> s emulsion?
        222169 EMULSION?
L12
=> s 112 and 111
       19 L12 AND L11
L13
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=>

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LOGINID:ssspta1503sxd

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TERMINAL (ENTER 1, 2, 3, OR ?):2

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NEWS 2
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NEWS 4 DEC 14
                2006 MeSH terms loaded in MEDLINE/LMEDLINE
NEWS 5 DEC 14 2006 MeSH terms loaded for MEDLINE file segment of TOXCENTER
NEWS 6 DEC 14 CA/CAplus to be enhanced with updated IPC codes
NEWS 7 DEC 21 IPC search and display fields enhanced in CA/CAplus with the
                IPC reform
NEWS 8 DEC 23
                New IPC8 SEARCH, DISPLAY, and SELECT fields in USPATFULL/
                USPAT2
NEWS 9 JAN 13 IPC 8 searching in IFIPAT, IFIUDB, and IFICDB
                New IPC 8 SEARCH, DISPLAY, and SELECT enhancements added to
NEWS 10
        JAN 13
                INPADOC
        JAN 17 Pre-1988 INPI data added to MARPAT
NEWS 11
        JAN 17 IPC 8 in the WPI family of databases including WPIFV
NEWS 12
                Saved answer limit increased
NEWS 13 JAN 30
NEWS 14 JAN 31
                Monthly current-awareness alert (SDI) frequency
                added to TULSA
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NEWS EXPRESS JANUARY 03 CURRENT VERSION FOR WINDOWS IS V8.01,

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AND CURRENT DISCOVER FILE IS DATED 19 DECEMBER 2005.

V8.0 USERS CAN OBTAIN THE UPGRADE TO V8.01 AT

http://download.cas.org/express/v8.0-Discover/

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=> file uspatfull COST IN U.S. DOLLARS

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NEWS 2
NEWS 3 DEC 05 CASREACT(R) - Over 10 million reactions available
NEWS 4 DEC 14 2006 MeSH terms loaded in MEDLINE/LMEDLINE
NEWS 5 DEC 14 2006 MeSH terms loaded for MEDLINE file segment of TOXCENTER
NEWS 6 DEC 14 CA/CAplus to be enhanced with updated IPC codes
        DEC 21 IPC search and display fields enhanced in CA/CAplus with the
NEWS 7
                IPC reform
NEWS 8 DEC 23 New IPC8 SEARCH, DISPLAY, and SELECT fields in USPATFULL/
                USPAT2
        JAN 13 IPC 8 searching in IFIPAT, IFIUDB, and IFICDB
NEWS 9
        JAN 13 New IPC 8 SEARCH, DISPLAY, and SELECT enhancements added to
NEWS 10
                INPADOC
        JAN 17 Pre-1988 INPI data added to MARPAT
NEWS 11
        JAN 17 IPC 8 in the WPI family of databases including WPIFV
NEWS 12
                Saved answer limit increased
NEWS 13
        JAN 30
        JAN 31 Monthly current-awareness alert (SDI) frequency
NEWS 14
```

NEWS EXPRESS JANUARY 03 CURRENT VERSION FOR WINDOWS IS V8.01,

CURRENT MACINTOSH VERSION IS V6.0c(ENG) AND V6.0Jc(JP),

AND CURRENT DISCOVER FILE IS DATED 19 DECEMBER 2005.

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NEWS HOURS STN Operating Hours Plus Help Desk Availability
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NEWS WWW CAS World Wide Web Site (general information)

Enter NEWS followed by the item number or name to see news on that specific topic.

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TOTAL

CA INDEXING COPYRIGHT (C) 2006 AMERICAN CHEMICAL SOCIETY (ACS)
FILE COVERS 1971 TO PATENT PUBLICATION DATE: 2 Feb 2006 (20060202/PD)

FILE LAST UPDATED: 2 Feb 2006 (20060202/ED)
HIGHEST GRANTED PATENT NUMBER: US6993790
HIGHEST APPLICATION PUBLICATION NUMBER: US2006026727

CA INDEXING IS CURRENT THROUGH 2 Feb 2006 (20060202/UPCA)

ISSUE CLASS FIELDS (/INCL) CURRENT THROUGH: 2 Feb 2006 (20060202/PD)

REVISED CLASS FIELDS (/NCL) LAST RELOADED: Dec 2005

USPTO MANUAL OF CLASSIFICATIONS THESAURUS ISSUE DATE: Dec 2005

=> s avobenzone? or Parsol 1789 439 AVOBENZONE? 1636 PARSOL 5697 1789

954 PARSOL 1789 (PARSOL(W)1789)

L1 1274 AVOBENZONE? OR PARSOL 1789

=> s zinc oxide? 250447 ZINC

685252 OXIDE?

L2 64772 ZINC OXIDE?

(ZINC(W)OXIDE?)

=> s l1 and l2

L3 811 L1 AND L2

=> s sunscreen? or uv or sunblock?

8768 SUNSCREEN?

176726 UV

733 SUNBLOCK?

L4 181493 SUNSCREEN? OR UV OR SUNBLOCK?

=> s 13 and 14

L5 804 L3 AND L4

=> s phenylbenzimidazole? sulfonic acid?

2010 PHENYLBENZIMIDAZOLE?

111185 SULFONIC

862757 ACID?

L6 338 PHENYLBENZIMIDAZOLE? SULFONIC ACID?

(PHENYLBENZIMIDAZOLE? (W) SULFONIC (W) ACID?)

=> s 15 and 16

L7 127 L5 AND L6

=> s 14/ti

416 SUNSCREEN?/TI

1984 UV/TI

16 SUNBLOCK?/TI

L8 2380 (SUNSCREEN?/TI OR UV/TI OR SUNBLOCK?/TI)

=> s 18 and 17

L9 52 L8 AND L7

=> s human? or skin?

```
10/645,253
        515861 HUMAN?
        244157 SKIN?
L10
        638504 HUMAN? OR SKIN?
=> s 110 and 19
L11
            52 L10 AND L9
=> s emulsion?
L12
        222169 EMULSION?
=> s 111 and 112
L13
            52 L11 AND L12
=> d his
     (FILE 'HOME' ENTERED AT 09:28:07 ON 07 FEB 2006)
     FILE 'USPATFULL' ENTERED AT 09:28:27 ON 07 FEB 2006
           1274 S AVOBENZONE? OR PARSOL 1789
L1
          64772 S ZINC OXIDE?
L2
L3
            811 S L1 AND L2
         181493 S SUNSCREEN? OR UV OR SUNBLOCK?
L4
L5
            804 S L3 AND L4
            338 S PHENYLBENZIMIDAZOLE? SULFONIC ACID?
L6
L7
            127 S L5 AND L6
L8
           2380 S L4/TI
L9
             52 S L8 AND L7
         638504 S HUMAN? OR SKIN?
L10
             52 S L10 AND L9
L11
         222169 S EMULSION?
L12
L13
             52 S L11 AND L12
=> s 11/clm
            87 AVOBENZONE?/CLM
            28 PARSOL/CLM
           223 1789/CLM
            22 PARSOL 1789/CLM
                 ((PARSOL(W)1789)/CLM)
           103 (AVOBENZONE?/CLM OR PARSOL 1789/CLM)
L14
=> s 114 and 113
L15
            13 L14 AND L13
=> d l15 1-13 ibib abs
    ANSWER 1 OF 13
                     USPATFULL on STN
L15
ACCESSION NUMBER:
                         2005:305299 USPATFULL
                         Cleansing foaming sunscreen lotion
TITLE:
                         Knopf, Michael A., Randolph, NJ, UNITED STATES
INVENTOR(S):
                         Polk, Michele, Flanders, NJ, UNITED STATES
                        Lucia, Frank A. III, Wantage, NJ, UNITED STATES
                        Wohland, William C., Succasunna, NJ, UNITED STATES
                         Macchio, Ralph, Sparta, NJ, UNITED STATES
                              NUMBER
                                           KIND
                                                    DATE
PATENT INFORMATION:
                        US 2005265936
                                            A1
                                                 20051201
APPLICATION INFO.:
                        US 2005-102579
                                            A1
                                                 20050408
                                                            (11)
                        Continuation-in-part of Ser. No. US 2004-710052, filed
RELATED APPLN. INFO.:
```

NUMBER DATE

on 15 Jun 2004, PENDING

\_\_\_\_\_\_

PRIORITY INFORMATION: US 2004-521565P 20040525 (60)

DOCUMENT TYPE: Utility FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, 1600 TCF TOWER,

121 SOUTH EIGHT STREET, MINNEAPOLIS, MN, 55402, US

NUMBER OF CLAIMS: 24
EXEMPLARY CLAIM: 1
LINE COUNT: 579

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

The invention described herein includes a sunscreen formulation comprising: a sunscreen, a structurant and an emulsion comprising a homogenized mixture of wax and alcohol components, at least one of which is a surfactant, wherein the formulation comprises a stable lamellar or spherulite phase.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 2 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2005:74630 USPATFULL

TITLE: Sunscreen compositions and methods of use

thereof

INVENTOR(S): Maniscalco, Thomas J., Danbury, CT, UNITED STATES

NUMBER KIND DATE
US 2005063924 A1 20050324

PATENT INFORMATION: US 2005063924 A1 20050324 APPLICATION INFO.: US 2004-805757 A1 20040322 (10)

RELATED APPLN. INFO.: Continuation of Ser. No. US 2003-444332, filed on 22

May 2003, ABANDONED

NUMBER DATE

PRIORITY INFORMATION: US 2002-383077P 20020523 (60)

DOCUMENT TYPE: Utility
FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: MINTZ, LEVIN, COHN, FERRIS, GLOVSKY, AND POPEO, P.C.,

ONE FINANCIAL CENTER, BOSTON, MA, 02111

NUMBER OF CLAIMS: 20 EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 1 Drawing Page(s)

LINE COUNT: 676

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

Disclosed herein are novel methods for reducing or preventing the harmful effects of solar radiation on skin. Also disclosed are novel sunscreen compositions comprising 3-[2-(4-diethylaminophenyl)-2-oxoethyl]thiazolium salt for reducing or preventing the harmful effects of solar radiation on skin.

Agents that provide UV-A and UV-B filters are also

Agents that provide UV-A and UV-B filters are also included. The invention further discloses additional sunscreen active agents, emollients, humectants, dry-feel modifiers, waterproofing agents, insect repellants, antimicrobial preservatives, antioxidants, chelating agents, fragrances and moisturizers, suitable carriers for topical application and emulsions.

topical application and emulsions.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 3 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2005:16380 USPATFULL Sunscreen composition

INVENTOR(S): Dueva-Koganov, Olga V., White Plains, NY, UNITED STATES

SaNogueira, James P., Suffern, NY, UNITED STATES

10/645,253

PATENT ASSIGNEE(S): Playtex Products, Inc. (U.S. corporation)

NUMBER KIND DATE
PATENT INFORMATION: US 2005013781 A1 20050120

APPLICATION INFO.: US 2004-856737 A1 20040528 (10)

NUMBER DATE

PRIORITY INFORMATION: US 2003-474362P 20030529 (60)

DOCUMENT TYPE: Utility FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: Charles N. J. Ruggiero, Esq., Ohlandt, Greeley,

Ruggiero & Perle, L.L.P., 10th Floor, One Landmark

Square, Stamford, CT, 06901-2682

NUMBER OF CLAIMS: 95
EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 7 Drawing Page(s)

LINE COUNT: 1831

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

There is provided a composition comprising one or more photoactive compounds and one or more optimization agents. Surprisingly, the composition requires a small amount of optimization agent to efficiently optimize the polarity, critical wavelength, SPF, PFA, Star Rating, photostability, or any combinations thereof, of the composition. Subsequently, an efficient sunscreen composition is achieved.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 4 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2004:291731 USPATFULL

TITLE: Sunscreen wipes having high sunscreen

formulation transfer rate

INVENTOR(S): Krzysik, Duane G., Appleton, WI, UNITED STATES

PATENT ASSIGNEE(S): Kimberly-Clark Worldwide, Inc. (U.S. corporation)

NUMBER KIND DATE

PATENT INFORMATION: US 2004228811 A1 20041118

APPLICATION INFO.: US 2003-436774 A1 20030513 (10)

DOCUMENT TYPE: Utility

FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: SENNIGER POWERS LEAVITT AND ROEDEL, ONE METROPOLITAN

SQUARE, 16TH FLOOR, ST LOUIS, MO, 63102

NUMBER OF CLAIMS: 111
EXEMPLARY CLAIM: 1
LINE COUNT: 1634

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

Sunscreen wipes comprising a thixotropic, quick-breaking sunscreen formulation are disclosed. The sunscreen formulation comprises water, at least one sunscreen active, Pemulen TR-2, a stabilizing emulsifier, and a neutralizing agent. By formulating the sunscreen formulation such that it has specific high shear and low shear viscosities at a pH range of from about 5 to about 6, the transfer rate of the sunscreen formulation to the skin during use is significantly increased

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 5 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2004:164854 USPATFULL

as compared to conventional sunscreen wipes.

10/645,253

TITLE: Sunscreen composition and methods for

manufacturing and using a sunscreen

composition

INVENTOR(S): Roszell, James A., Henderson, NV, UNITED STATES

NUMBER KIND DATE

PATENT INFORMATION: US 2004126339 A1 20040701

APPLICATION INFO.: US 2002-335192 A1 20021231 (10)

DOCUMENT TYPE: Utility FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: MERCHANT & GOULD PC, P.O. BOX 2903, MINNEAPOLIS, MN,

55402-0903

NUMBER OF CLAIMS: 26
EXEMPLARY CLAIM: 1
LINE COUNT: 1084

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB A sunscreen composition is provided. The sunscreen

composition includes a mixture of a **skin** bonding polymer composition comprising hydrophobic polymer/hydrophilic polymer adduct,

at least one sunscreen active ingredient in an amount effective to provide the sunscreen with an SPF value of at

least 4, and water in an amount effective to provide the composition

with a texture suitable for application to skin. The

hydrophobic polymer/hydrophilic polymer adduct can be prepared by melt processing a hydrophobic polymer composition that includes repeating pyrrolidone/alkylene groups wherein the alkylene groups contain at least 10 carbon atoms, and a hydrophilic polymer composition including

repeating carboxylic groups and/or repeating hydroxyl groups. Methods for manufacturing and using a sunscreen are provided.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 6 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2004:164852 USPATFULL Sunscreen compositions

INVENTOR(S): Singleton, Laura C., Los Angeles, CA, UNITED STATES

DOCUMENT TYPE: Utility FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: PHILIP S. JOHNSON, JOHNSON & JOHNSON, ONE JOHNSON &

JOHNSON PLAZA, NEW BRUNSWICK, NJ, 08933-7003

NUMBER OF CLAIMS: 20 EXEMPLARY CLAIM: 1 LINE COUNT: 461

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB The present invention relates to a composition containing (i) a

lipophilic sunscreen, (ii) a copolymer of sodium

acryloyldimethyltaurate and one or more acryls, and (iii) an

oil-absorbant.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 7 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2004:158109 USPATFULL

TITLE: Sunscreen compositions and methods of use

thereof

INVENTOR(S): Gall, Martin, Morristown, NJ, UNITED STATES

Pagan, Miguel, Howells, NY, UNITED STATES

NUMBER DATE

PRIORITY INFORMATION: US 2002-383284P 20020523 (60)

DOCUMENT TYPE: Utility FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: MINTZ, LEVIN, COHN, FERRIS, GLOVSKY, AND POPEO, P.C.,

ONE FINANCIAL CENTER, BOSTON, MA, 02111

NUMBER OF CLAIMS: 20 EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 1 Drawing Page(s)

LINE COUNT: 749

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

Disclosed herein are novel methods for reducing or preventing the harmful effects of solar radiation on skin. Also disclosed are novel sunscreen compositions comprising thaizolium, thiadiazolium or triazolium compounds or derivatives and analogs thereof for reducing or preventing the harmful effects of solar radiation on skin. Sunscreen active agents that provide UV

-A and UV-B filters are also included. The invention further discloses additional sunscreen active agents, emollients, humectants, dry-feel modifiers, waterproofing agents, insect repellants, antimicrobial preservatives, antioxidants, chelating agents, fragrances and moisturizers, suitable carriers for topical application and emulsions.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 8 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2003:276359 USPATFULL

TITLE: Methods of making and selling a sunscreen

composition

INVENTOR(S): Bonda, Craig A., Winfield, IL, UNITED STATES

PATENT ASSIGNEE(S): The C.P. Hall Company (U.S. corporation)

KIND NUMBER DATE US 2003194384 A1 20031016 PATENT INFORMATION: US 6770270 B2 20040803 APPLICATION INFO.: US 2002-105990 A1 20020325 (10) Continuation-in-part of Ser. No. US 2002-92132, filed RELATED APPLN. INFO.: on 5 Mar 2002, GRANTED, Pat. No. US 6485713 Continuation-in-part of Ser. No. US 2002-92131, filed on 5 Mar 2002, GRANTED, Pat. No. US 6537529 Utility DOCUMENT TYPE:

FILE SEGMENT: Utility
APPLICATION

LEGAL REPRESENTATIVE: MARSHALL, GERSTEIN & BORUN, 6300 SEARS TOWER, 233 SOUTH

WACKER, CHICAGO, IL, 60606-6357

NUMBER OF CLAIMS: 20 EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 4 Drawing Page(s)

LINE COUNT: 1635

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB A method of preparing a sunscreen including a solvent system and a filter system, the method including the step of controlling the polarity of the solvent system to control the rate of photodecay of the

filter system, as well as sunscreen compositions and compounds for producing sunscreen compositions, are disclosed. A method of selling a cosmetically-acceptable sunscreen composition is disclosed.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 9 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2003:81440 USPATFULL

TITLE: Sunscreen compositions and methods and

materials for producing the same

INVENTOR(S): Bonda, Craig A., Winfield, IL, United States

PATENT ASSIGNEE(S): The C.P. Hall Company, Chicago, IL, United States (U.S.

corporation)

PATENT INFORMATION: US 6537529 B1 20030325 APPLICATION INFO.: US 2002-92131 20020305 (10)

DOCUMENT TYPE: Utility FILE SEGMENT: GRANTED

PRIMARY EXAMINER: Dodson, Shelley A.

LEGAL REPRESENTATIVE: Marshall, Gerstein & Borun

NUMBER OF CLAIMS: 14
EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 6 Drawing Figure(s); 6 Drawing Page(s)

LINE COUNT: 1423

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB A method of preparing a sunscreen including a solvent system and a filter system, the method including the step of controlling the polarity of the solvent system to control the rate of photodecay of the filter system, as well as sunscreen compositions and compounds

for producing sunscreen compositions, are disclosed.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 10 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2002:310621 USPATFULL

TITLE: Sunscreen compositions and methods and

materials for producing the same

INVENTOR(S): Bonda, Craig A., Winfield, IL, United States
Shah, Urvil B., Mokena, IL, United States

Mcmillin, Robert J., Oak Lawn, IL, United States

Roth, Magda M., Homewood, IL, United States

20020305 (10)

PATENT ASSIGNEE(S): The C. P. Hall Company, Chicago, IL, United States

(U.S. corporation)

APPLICATION INFO.: US 2002-92132 DOCUMENT TYPE: Utility

FILE SEGMENT: GRANTED
PRIMARY EXAMINER: Dodson, Shelley A.

LEGAL REPRESENTATIVE: Marshall, Gerstein & Borun

NUMBER OF CLAIMS: 69
EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 6 Drawing Figure(s); 3 Drawing Page(s)

LINE COUNT: 1768

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB A method of preparing a sunscreen including a solvent system and a filter system, the method including the step of controlling the

polarity of the solvent system to control the rate of photodecay of the filter system, as well as **sunscreen** compositions and compounds for producing **sunscreen** compositions, are disclosed.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 11 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2001:237461 USPATFULL

TITLE: Delivery systems for active ingredients including

sunscreen actives and methods of making same

INVENTOR(S): Deblasi, Douglas S., Fairfield, NJ, United States

Sui, Manshi, Hillsborough, NJ, United States

Pe, Roy, Kendall Park, NJ, United States

PATENT ASSIGNEE(S): Shamrock Technologies (U.S. corporation)

APPLICATION INFO.: US 2001055573 A1 20011227

APPLICATION INFO.: US 2001-875614 A1 20010606 (9)

RELATED APPLN. INFO.: Continuation of Ser. No. US 1999-374862, filed on 16

Aug 1999, GRANTED, Pat. No. US 6280710

DOCUMENT TYPE: Utility FILE SEGMENT: APPLICATION

LEGAL REPRESENTATIVE: BAKER BOTTS LLP, 44TH FLOOR, 30 ROCKEFELLER PLAZA, NEW

YORK, NY, 10112-4498

NUMBER OF CLAIMS: 36
EXEMPLARY CLAIM: 1
LINE COUNT: 1223

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

The present invention provides methods of making delivery systems for active ingredients including hydrogenated jojoba and sunscreen actives. The recrystallization process of the present invention produces small particle size alloys from molten mixtures and recrystallized small particle size dispersions from high temperature solvent solutions. The invention further provides delivery systems for active ingredients such as sunscreen actives.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 12 OF 13 USPATFULL on STN

ACCESSION NUMBER: 2001:141860 USPATFULL

TITLE: Delivery systems for active ingredients including

sunscreen actives and methods of making same

INVENTOR(S): Deblasi, Douglas S., Fairfield, NJ, United States

Sui, Manshi, Hillsborough, NJ, United States

De Des Verdell Desle NT United Chates

Pe, Roy, Kendall Park, NJ, United States

PATENT ASSIGNEE(S): Shamrock Technologies, Inc., Newark, NJ, United States

(U.S. corporation)

APPLICATION INFO.: US 1999-374862 19990816 (9)
RELATED APPLN. INFO.: Continuation of Ser. No. US 1997-843032, filed on 11

Apr 1997, now patented, Pat. No. US 6036945

DOCUMENT TYPE: Utility FILE SEGMENT: GRANTED

PRIMARY EXAMINER: Dodson, Shelley A.

NUMBER OF CLAIMS: 26
EXEMPLARY CLAIM: 1
LINE COUNT: 1127

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

INVENTOR(S):

The present invention provides methods of making delivery systems for AB active ingredients including hydrogenated jojoba and sunscreen actives. The recrystallization process of the present invention produces small particle size alloys from molten mixtures and recrystallized small particle size dispersions from high temperature solvent solutions. The invention further provides delivery systems for active ingredients such as sunscreen actives.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L15 ANSWER 13 OF 13 USPATFULL on STN

2000:31019 USPATFULL ACCESSION NUMBER:

Delivery systems for active ingredients including TITLE:

sunscreen actives and methods of making same

Deblasi, Douglas S., Fairfield, NJ, United States

Sui, Manshi, Hillsborough, NJ, United States

Pe, Roy, Kendall Park, NJ, United States

Shamrock Technologies, Inc., Newark, NJ, United States PATENT ASSIGNEE(S):

(U.S. corporation)

NUMBER KIND DATE PATENT INFORMATION: US 6036945 20000314 US 1997-843032 APPLICATION INFO.: 19970411 (8)

Utility

DOCUMENT TYPE:

Granted FILE SEGMENT:

Dees, Jose' G. PRIMARY EXAMINER:

Shelborne, Kathryne E. ASSISTANT EXAMINER: Baker & Botts, LLP LEGAL REPRESENTATIVE:

NUMBER OF CLAIMS: 42 EXEMPLARY CLAIM: 1 LINE COUNT: 1425

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

The present invention provides methods of making delivery systems for ABactive ingredients including hydrogenated jojoba and sunscreen actives. The recrystallization process of the present invention produces small particle size alloys from molten mixtures and recrystallized small particle size dispersions from high temperature solvent solutions. The invention further provides delivery systems for active ingredients such as sunscreen actives.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

## 10/645,253 => d his (FILE 'HOME' ENTERED AT 09:28:07 ON 07 FEB 2006) FILE 'USPATFULL' ENTERED AT 09:28:27 ON 07 FEB 2006 1274 S AVOBENZONE? OR PARSOL 1789 L164772 S ZINC OXIDE? L2811 S L1 AND L2 L3 181493 S SUNSCREEN? OR UV OR SUNBLOCK? L4L5804 S L3 AND L4 338 S PHENYLBENZIMIDAZOLE? SULFONIC ACID? L6127 S L5 AND L6 L72380 S L4/TI L8L9 52 S L8 AND L7 638504 S HUMAN? OR SKIN? L1052 S L10 AND L9 L11222169 S EMULSION? L12 L1352 S L11 AND L12 103 S L1/CLM L14 13 S L14 AND L13 L15 1 S US6036945/PN L16 1 S L16 AND L15 L17 => s stabili? or photodegration? 902742 STABILI? 22 PHOTODEGRATION? L18 902744 STABILI? OR PHOTODEGRATION? => s 113 and 118 . L19 48 L13 AND L18 => s 16(p)118L20 7 L6(P)L18 => d 120 and 119 L19 IS NOT VALID HERE For an explanation, enter "HELP DISPLAY". => s 120 and 119 L21 2 L20 AND L19 => d 1-2 ibib abs L21 ANSWER 1 OF 2 USPATFULL on STN ACCESSION NUMBER: 2002:224254 USPATFULL Sunscreen compositions containing a TITLE: dibenzoylmethane derivative Cole, Curtis, Ringoes, NJ, United States INVENTOR(S): Natter, Florence, Hillsborough, NJ, United States Johnson & Johnson Consumer Companies, Inc., Skillman, PATENT ASSIGNEE(S): NJ, United States (U.S. corporation)

	NUMBER	KIND	DATE	
PATENT INFORMATION: APPLICATION INFO.: DOCUMENT TYPE: FILE SEGMENT: PRIMARY EXAMINER: LEGAL REPRESENTATIVE: NUMBER OF CLAIMS:	US 6444195 US 2001-883416 Utility GRANTED Dodson, Shelley A. Harriman, Erin M.	B1	20020903	(9)

EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 0 Drawing Figure(s); 0 Drawing Page(s)

LINE COUNT: 485

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

The present invention relates to a method of photostabilizing a composition comprising (a) one or more dibenzoylmethane derivative UV-A absorbing agent(s); (b) one or more benzophenone derivative(s); and (c) a diester or polyester of a naphthalene dicarboxylic acid and a method of protecting mammalian skin or hair from UV radiation comprising topically applying to the skin or hair such a composition.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L21 ANSWER 2 OF 2 USPATFULL on STN

ACCESSION NUMBER: 1999:155173 USPATFULL

TITLE: Photostable sunscreen compositions containing

dibenzoylmethane derivative, E.G., parsol® 1789,

and diesters or polyesters of naphthalene dicarboxylic

acid photostabilizers and enhancers of the sun

protection factor (SPF)

INVENTOR(S): Bonda, Craig A., Wheaton, IL, United States

Marinelli, Peter J., Bartlett, IL, United States Hessefort, Yin Z., Naperville, IL, United States Trivedi, Jagdish, Woodridge, IL, United States

Wentworth, Gary, Chicago, IL, United States

PATENT ASSIGNEE(S): The C.P. Hall Company, Chicago, IL, United States (U.S.

corporation)

NUMBER KIND DATE

PATENT INFORMATION: US 5993789 19991130 APPLICATION INFO.: US 1999-276051 19990325 (9)

DOCUMENT TYPE: Utility FILE SEGMENT: Granted

PRIMARY EXAMINER: Dodson, Shelley A.

LEGAL REPRESENTATIVE: Marshall, O'Toole, Gerstein, Murray & Borun

NUMBER OF CLAIMS: 20 EXEMPLARY CLAIM: 1

NUMBER OF DRAWINGS: 9 Drawing Figure(s); 9 Drawing Page(s)

LINE COUNT: 532

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB A sunscreen composition containing a UV-A dibenzoylmethane derivative, such as 4-(1,1-dimethylethyl)-4'-methoxydibenzoylmethane (PARSOL® 1789), and a stabilizer for the dibenzoylmethane derivative having formula (I) or (II), or mixtures: ##STR1## wherein each R.sup.1, same or different, is an alkyl group having 1 to 22 carbon atoms, a diol having the structure HO--R.sup.2 --OH, or a polyglycol having the structure HO--R.sup.3 --(--O--R.sup.2 --).sub.m --OH, wherein R.sup.2 and R.sup.3, same or different, are each an alkylene group, straight chain or branched, having 1 to 6 carbon atoms, and wherein m and n are each 1 to about 100, or a mixture thereof. These diesters and polyesters of formula (I) or (II) are quite effective in stabilizing the dibenzoylmethane derivative UV-A filter compounds making them more effective, and effective for longer periods of time.

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

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L22 0 US59937789/PN

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=> s us5993789/pn
             1 US5993789/PN
L23
=> d his
     (FILE 'HOME' ENTERED AT 09:28:07 ON 07 FEB 2006)
     FILE 'USPATFULL' ENTERED AT 09:28:27 ON 07 FEB 2006
           1274 S AVOBENZONE? OR PARSOL 1789
L1
          64772 S ZINC OXIDE?
L2
            811 S L1 AND L2
L3
         181493 S SUNSCREEN? OR UV OR SUNBLOCK?
L4
L5
            804 S L3 AND L4
            338 S PHENYLBENZIMIDAZOLE? SULFONIC ACID?
L6
            127 S L5 AND L6
L7
           2380 S L4/TI
L8
L9
             52 S L8 AND L7
         638504 S HUMAN? OR SKIN?
L10
             52 S L10 AND L9
L11
L12
         222169 S EMULSION?
             52 S L11 AND L12
L13
            103 S L1/CLM
L14
L15
             13 S L14 AND L13
              1 S US6036945/PN
L16
              1 S L16 AND L15
L17
L18
         902744 S STABILI? OR PHOTODEGRATION?
             48 S L13 AND L18
L19
              7 S L6(P)L18
L20
              2 S L20 AND L19
L21
L22
              0 S US59937789/PN
              1 S US5993789/PN
L23
=> s 123 and 121
L24
             1 L23 AND L21
=> d kwic
L24 ANSWER 1 OF 1 USPATFULL on STN
       Photostable sunscreen compositions containing dibenzoylmethane
TI
       derivative, E.G., parsol® 1789, and diesters or polyesters of
       naphthalene dicarboxylic acid photostabilizers and enhancers of the. .
       US 5993789
PI
                               19991130
       A sunscreen composition containing a UV-A
AB
       dibenzoylmethane derivative, such as 4-(1,1-dimethylethyl)-4'-
       methoxydibenzoylmethane (PARSOL® 1789), and a stabilizer
       for the dibenzoylmethane derivative having formula (I) or (II), or
       mixtures: ##STR1## wherein each R.sup.1, same or different, is an.
       to about 100, or a mixture thereof. These diesters and polyesters of
       formula (I) or (II) are quite effective in stabilizing the
       dibenzoylmethane derivative UV-A filter compounds making them
       more effective, and effective for longer periods of time.
       The present invention is directed to a photostable, broad spectrum (
SUMM
       UV-A/UV-B), stable sunscreen composition for
       topical application to human skin to protect the
       skin against UV radiation damage. More particularly,
       the present invention is directed to the use of diesters and/or
       polyesters of a naphthalene dicarboxylic acid that are surprisingly
       effective in photostabilizing dibenzoylmethane derivatives, particularly
       4-(1,1-dimethylethyl)-4'-methoxydibenzoylmethane (avobenzone
       or PARSOL® 1789). The diesters and polyesters of naphthalene
```

dicarboxylic acid photostabilize the PARSOL® 1789 and improve the Sun Protection Factor (SPF) to provide a more effective sunscreen composition compared to currently marketed sunscreens having the same or higher levels of UV absorbing active ingredients. This improved performance means the composition maintains its level of effectiveness over a longer period of time and, therefore, need not be applied to the skin as frequently. Other sunscreen agents can be included, such as octyl methoxycinnamate (UV-B), benzophenone 3 (UV-A/ UV-B) (a/k/a oxybenzone), octyl salicylate (UV-B), octyl triazone (UV-B), phenylbenzimidazole sulfonic acid (UV-B), methylbenzilidene camphor (UV-A/UV-B), or octocrylene (UV-A/ UV-B) to increase the SPF to a value of at least 2, preferably at least 8, while maintaining the stabilization of the dibenzoylmethane derivative UV-A sunscreen agent, e.g., PARSOL 1789.

It is well known that ultraviolet light having a wavelength between about 280 nm or 290 nm and 320 nm (UV-B) is harmful to human skin, causing burns that are detrimental to the development of a good sun tan. UV-A radiation, while producing tanning of the skin, also can cause damage, particularly to very lightly colored, sensitive skin, leading to reduction of skin elasticity and wrinkles.

SUMM Therefore, a sunscreen composition should include both UV-A and UV-B filters to prevent most of the sunlight within the full range of about 280 nm to about 400 nm from damaging human skin.

SUMM The UV-B filters that are most widely used commercially in sunscreen compositions are paramethoxycinnamic acid esters, such as 2-ethylhexyl paramethoxycinnamate, commonly referred to as octyl methoxycinnamate or PARSOL® MCX, having an.

The UV-A filters most commonly used in commercial SUMM sunscreen compositions are the dibenzoylmethane derivatives, particularly 4-(1,1-dimethylethyl)-4'-methoxydibenzoylmethane (PARSOL® 1789), and 4-isopropyl dibenzoylmethane (EUSOLEX 8020). Other dibenzoylmethane derivatives described as UV-A filters are disclosed in U.S. Pat. Nos. 4,489,057; 4,387,089 and 4,562,067 and 5,670,140, hereby incorporated by reference. It is also well known that the above described and most commonly used UV-A filters, particularly the dibenzoylmethane derivatives, such as PARSOL® 1789, suffer in photochemical stability when used alone or in combination with the above-described most commercially used UV -B filters. Accordingly, when used alone or when combined with a UV-B filter, such as 2-ethylhexyl paramethoxycinnamate (PARSOL® MCX), oxybenzone and/or octyl salicylate, the PARSOL® 1789 becomes less photochemically stable necessitating repeated, frequent coatings over the skin for sufficient UV radiation protection. SUMM

. . . that by including a diester and/or polyester of one or more naphthalene dicarboxylic acids of formula (I), into a cosmetic sunscreen formulation containing a UV-A dibenzyolmethane derivative, particularly PARSOL® 1789, and/or 4-isopropyl dibenzoylmethane (EUSOLEX 8020), the dibenzyolmethane derivative is photochemically stabilized so that the dibenzyolmethane derivative-containing sunscreen composition with or without additional sunscreen agents, such as oxybenzone and/or octyl methoxycinnamate (ESCALOL 567), is more effective for filtering out UV-A radiation; the composition filters more UV-A radiation for longer periods of time; and, therefore, the sunscreen formulation need not be applied to the skin as frequently while maintaining effective

skin protection against UV-A radiation.

SUMM . . . of the present invention, it has been found that the diesters and polyesters of naphthalene dicarboxylic acids can also absorb UV light in the most damaging range of about 280-300 nm, especially over the 280 and 295 nm wavelength absorbance peaks shown in FIG. 9, to further boost the SPF of the sunscreen compositions.

By the addition of UV-B filter compounds, such as octyl SUMM methoxycinnamate, octyl salicylate, and/or oxybenzone, the cosmetic sunscreen formulation can maintain surprisingly effective skin protection against UV radiation both in the UV-A and UV-B range, with or without common sunscreen additives, such as octocrylene, and/or titanium dioxide. The composition reaches a surprisingly high SPF without solid additives, such as titanium. . . dioxide, thereby providing an exceptionally elegant feel that can be applied easily in a continuous coating for complete coverage and sunscreen protection. The ratio of UV-A to UV-B filter compounds is in the range of about 0.1:1 to about 3:1, preferably about 0.1:1 to about 0.5:1, most preferably. . . preferred composition, and higher than SPF 20 in another preferred composition, with the addition of surprisingly low amounts of other UV-B and UV-A filters to the PARSOL 1789, and without solid blocking compounds, such as TiO.sub.2.

SUMM In brief, the present invention is directed to sunscreen compositions containing a dibenzoylmethane derivative UV-A filter compound, such as 4-(1,1-dimethylethyl)-4'-methoxydibenzoylmethane (PARSOL® 1789), and a diester and/or polyester of a naphthalene dicarboxylic acid that photostabilizes the.

SUMM Surprisingly, it has been found that these diesters and polyesters of naphthalene dicarboxylic acids are quite effective in stabilizing the dibenzoylmethane derivative UV-A filter compounds making them more effective; effective for longer periods of time; and, therefore, the sunscreen composition need not be reapplied as frequently to maintain effective UV radiation skin protection.

SUMM Accordingly, one aspect of the present invention is to provide a stable sunscreen composition that includes a diester or polyester of one or more naphthalene dicarboxylic acids as a photostabilizer compound, said naphthalene dicarboxylic acid diester/polyester photostabilizers having formula (I) or (II), being capable of stabilizing a dibenzoylmethane derivative UV-A filter, particularly PARSOL® 1789.

Another aspect of the present invention is to provide photochemical stabilizer compounds for dibenzoylmethane derivatives, particularly PARSOL® 1789, and methods of manufacturing the stabilizer compounds, capable of stabilizing the dibenzoylmethane derivatives, and capable of increasing the sunscreen protection factor (SPF) achievable for sunscreen compositions containing the dibenzoylmethane derivatives to a SPF of at least 2, particularly higher than SPF 8.

Another aspect of the present invention is to provide a stable sunscreen composition that has a SPF of at least 12, preferably at least about 20, without a sunscreen composition additive selected from the group consisting of octocrylene or camphor derivatives such as methylbenzilidene camphor or substituted dialkylbenzalmalonates or substituted dialkylmalonates, or solid blocking agents such as TiO.sub.2 or zinc oxide. It should be understood however, that these sunscreen composition additives can be included in the composition of the present invention without detrimental effect.

- SUMM Another aspect of the present invention is to provide an improved, stable sunscreen composition containing a diester and/or polyester of a naphthalene dicarboxylic acid that increases the effectiveness of dibenzoylmethane derivative sunscreen compounds, particularly 4-(1,1-dimethylethyl)-4'-methoxydibenzoylmethane (PARSOL® 1789), in SPF and in duration.
- SUMM Another aspect of the present invention is to provide a stable, broad spectrum sunscreen composition that has a SPF of at least 12 and provides substantial protection against the full range of solar UV radiation (280-400 nm), including about 4-15% by weight of an ester and/or polyester of naphthalene dicarboxylic acid, and contains less than 7% and preferably less than 6.1% of sunscreen composition additives selected from the group oxybenzone and avobenzone (PARSOL 1789).
- SUMM Still another aspect of the present invention is to provide a sunscreen composition containing a combination of acrylate/C.sub.10-30 alkyl acrylate block copolymers, e.g., PEMULEN TR-1 and PEMULEN TR-2, in a weight ratio. . .
- SUMM . . . ratio of 1:1-2:1 TR-1:TR:2 emulsify the compositions of the present invention such that the composition can be spread over the skin without gas bubbles or voids while providing a non-greasy after feel, and providing sufficient viscosity, and complete emulsification of the oil phase of the composition so that complete coverage of the skin is achieved, without interfering with the high SPF provided by the sunscreen and stabilizer compounds of the composition.
- SUMM Still another aspect of the present invention is to provide a moisturizing sunscreen composition that provides an SPF of at least 20, including about 4-15% by weight of an ester and/or polyester of. . . weight PARSOL® 1789 and less than a total of 7% by weight, preferably about 6% by weight or less of sunscreen composition additives selected from the group consisting of octyl methoxycinnamate, oxybenzone, octyl triazone, and octyl salicylate, preferably 2% by weight. . .
- DRWD FIG. 2 is a graph showing the photostability (photoinstability) or UV absorbance capability, of a sunscreen composition containing 1% by weight avobenzone when subjected to ultraviolet light of varying wavelengths;
- DRWD FIG. 3 is a graph showing photostability, or **uv** absorbance capability, of a **sunscreen** compositing containing 1% by weight **avobenzone** when **stabilized** with 4% by weight of one of the naphthalene dicarboxylic acid polyesters of the present invention;
- DRWD FIG. 4 is a graph showing photostability, or **UV** absorbance capability, of a **sunscreen** composition containing 1% by weight **avobenzone** when **stabilized** with 8% by weight of one of the naphthalene dicarboxylic acid polyesters of the present invention;
- DRWD FIG. 5 is a graph showing the photostability of a sunscreen composition containing 3% by weight oxybenzone/1% by weight avobenzone, without a photostabilizer of the present invention;
- DRWD FIG. 6 is a graph showing the photostability of a sunscreen composition containing 3% by weight oxybenzone/1% by weight avobenzone, and 8% by weight of one of the naphthalene dicarboxylic acid polyester photostabilizers of the present invention;
- DRWD FIG. 7 is a graph showing the photostability of a sunscreen composition containing 1% by weight avobenzone and 4% by weight of an octocrylene photostabilizer;
- DRWD FIG. 8 is a graph showing the photostability of a sunscreen composition containing 1% by weight avobenzone and 4% by weight of an oligomer (MW=.about.1500) of a naphthalene dicarboxylic acid ester of the present invention; and
- DRWD FIG. 9 is a graph showing the **UV** absorbance of the naphthalic dicarboxylic acid of Example 1 at 17.5 ppm in tetrahydroforan (THF).

The sunscreen compositions of the present invention include DETD about 0.5% to about 5%, preferably about 0.5% to about 3% of a dibenzoylmethane derivative UV-A filter compound, such as 4-(1,1-dimethylethyl)-4'-methoxy-dibenzoylmethane (PARSOL® 1789) and about 1% to about 10% by weight of a diester and/or polyester. . .

DETD

Formula A

Ingredient (Standard)

Formula B

Formula C Function

				Function
hexyld	ecyl benzoate			<del></del>
-	7.50%	7.50%	7.50%	emollient,
&				solvent
butylo	ctyl benzoate			
isopro	pyl myristate			
	5.00%	5.00%	1.00%	co-solvent
avob	enzone 1.00%	1.00%	1.00	% <b>UV</b> -A
				sunscreen
myrist	yl myristate			
	4.00%	0.00%	0.00%	bodying
				agent
polyes				
	0.00%	4.00%	8.00%	photostabilizer
-	phthalene			
	oxylic acid			
sorbit	an oleate			
	0.20%	0.20%	0.20%	particle size
A J 1.	·			reducer
dimeth		0 100	0 108	lubad comb
	0.10%	0.10%	0.10%	lubricant
copoly		0 208	0 208	thiakanar
carbom	er 0.20%	0.20%	0.208	thickener, stabilizer
ລອກນໄລ	+07/010 30			Blabilizer
acryra	tes/C10-30 0.25%	0 258	በ 25%	emulsifier
alkvl	acrylates	0.25%	0.25%	emuisiliei
_	olymer			
_	zed water			
uc.rom		Q.S.	0.8	solvent
	Q.5.	Q.D.	<b>Q.</b>	carrier
disodi	um EDTA			
		0.05%	0.05%	chelator
hydrox	ypropyl-			
4		0.20%	0.20%	film
DETD	The photosta	bility of	the PA	RSOL® 1789 was determined by spreading
	measured amo	unts of t	he emul	sions on 5 cm square slides of
	Vitro-skin,	then irra	diating	the slides with a solar
	simulator. A	bsorbance	measur	ements in the <b>uv</b> -A range (315-380
	nm) were tak	en by a L	abspher	e <b>UV</b> Transmittance Analyzer before
	and after ir	radiation	and th	e results compared.
DETD				(minimal erythermal dose), the loss of
				L® 1789 was considerably lower
				ng the PARSOL® 1789 in combination with
				on containing the PARSOL® 1789 alone
	~	·		Further, the loss of absorbance in the
	•			anner related to the concentration
	of the napht	halene di	carboxy	lic polymer, as can be seen in
DETD				

Ingredient Formula A

## Function

hexyldecyl benze	oate &		<del></del>
nonjidooji bolib	7.50%	7.50%	emollient,
butyloctyl benz		,.500	solvent
isopropyl myris			
	5.00%	5.00%	co-solvent
avobenzone	1.00%	1.00%	UV-A
			sunscreen
octocrylene	4.00%	0.00%	UV-B/UV-A
•			sunscreen
polyester of 2,	6-naphtha	lene	
	0.00%	4.00%	photostabilizer
dicarboxylic ac	id		
sorbitan oleate	0.20%	0.20%	particle size
			reducer
dimethicone cope	olyol		
	0.10%	0.10%	lubricant
carbomer	0.20%	0.20%	thickener,
			stabilizer
acrylates/C10-3	-	-	3 161
	0.25%	0.25%	emulsifier
crosspolymer	0 0	0 0	
deionized water	Q.S.	Q.S.	solvent,
diandium EDMA	0 05%	0 05%	carrier
disodium EDTA			chelator
hydroxypropylme	0.20%		film former
glycerin	4.00%		IIIII TOLIIIEI
DETD	4.005	4.005.	•
	Formula	Δ	
		ormula B	
	-		
Average loss of	UV-A		<del></del>
3	26.33%	22.36%	
Average loss of	<b>UV</b> -B		
-	25.15%	18.29%	
Average loss of	SPF		
	26.82%	20.35%	

CLM What is claimed is:

- 1. A sunscreen composition having an SPF of at least 2, for topical application to human skin for protection against ultraviolet radiation comprising, in a cosmetically acceptable carrier, at least about 0.5% by weight of a dibenzoylmethane. . . 2. A composition in accordance with claim 1, wherein the molar ratio of said stabilizing compound having formula (I) or (II) to said dibenzoylmethane derivative is about 0.1:1 to about 10:1.
- 3. A composition in accordance with claim 1, wherein the molar ratio of said **stabilizing** compound having formula (I) or (II) to said dibenzoylmethane derivative is about 0.1:1 to about 0.3:1.
- 8. A composition in accordance with claim 7, wherein the **stabilizing** compound is included in the composition in an amount of about 1% to about 20% by weight of the composition.
- 9. A composition in accordance with claim 7, wherein the **stabilizing** compound is a polyester of 2,6-naphthalene dicarboxylic acid.
- 10. A method of filtering out ultraviolet radiation from human

skin comprising topically applying to said skin a
composition, in a cosmetically acceptable carrier, comprising 0.5% to 5%
by weight of a dibenzoylmethane derivative and a diester or polyester of
a naphthalene dicarboxylic acid stabilizing compound selected
from the group consisting of formula (I), formula (II) and mixtures
thereof: ##STR8## wherein each R.sup.1, same or. . .
11. A method in accordance with claim 10, wherein the molar ratio of
said stabilizing compound having formula (I) or (II) to said
dibenzoylmethane derivative is about 0.1:1 to about 10:1.

- 12. A method in accordance with claim 10, wherein the molar ratio of said stabilizing compound having formula (I) to said dibenzoylmethane derivative is about 0.1:1 to about 0.3:1.
- 16. A method of filtering out ultraviolet radiation from human skin comprising topically applying to said skin, in a cosmetically acceptable carrier, a diester or polyester of a naphthalene dicarboxylic acid compound selected from the group consisting. . . 17. A sunscreen composition including the stabilizer defined in claim 1, having the following composition:

```
8 W/W
Chemical Name
Dibenzoylmethane derivative
                          1-10
  Stabilizer of claim 1
                            1-15
Octocrylene
                          0 - 10
Hexyldecyl benzoate & Butyloctyl benzoate
                          0 - 10
  UV-A/UV-B sunscreen #1 0-10
  UV-A/UV-B sunscreen #2
                            0-10
                            0 - 10
  UV-A/UV-B sunscreen #3
  UV-A/UV-B sunscreen #4
                            0 - 10
Dimethicone copolyol
                         0 - 2
Isopropyl myristate
                         0-5
Oxybenzone
                         0 - 8
Thickener
                         0 - 2
Sorbitan oleate
                         0-5
Acrylate/C.sub.10-30 alkyl acrylate crosspolymer
                         0-5
                         50-90
Water
Carbomer
                         0-2
Disodium EDTA
                         0-2
Glycerin
                          0 - 10
Butylene glycol.
18. The sunscreen composition of claim 17 having the following
composition:
                           & W/W
Chemical Name
4-(1,1-dimethylethyl)-4'-methoxydibenzoylmethane
                           1-10
  Stabilizer of claim 1
                             1-15
Butyloctyl salicylate
                           5-10
  UV-A/UV-B sunscreen
                             0.5 - 10
                           50-90
Water
```

19. A sunscreen composition including the stabilizer defined in claim 1, having the following composition:

Dibenzoylmethane derivative Polyester of 2,6-naphthalene dicarboxylic acid 1-10 Octocrylene 1-5 Butyloctyl salicylate 5-10 UV-B/UV-A sunscreen 0.5 - 5Isopropyl myristate 3 - 7 Acrylate/C.sub.10-30 alkyl acrylate crosspolymer 0.1-1 50-90 Water 0.1-0.5 Carbomer Phenoxyethanol()methyl 0.1-1 paraben()ethylparaben()propylparaben()butylparaben

20. A sunscreen composition including the stabilizer defined in claim 1, having the following composition:

Chemical Name	% W/W			
Dibenzoylmethane d	derivative			
	1-8			
Stabilizer of claim 1				
	1-10			
Butyloctyl salicylate				
	1-10			
UV-A sunscreen	0.5-5			
Water	50-90			

=>